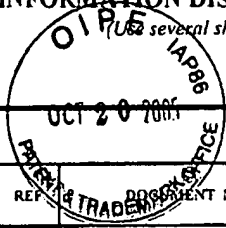


# INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)



Docket Number (Optional)

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Applicant(s)

Jeong-Hwan LEE, et al.

Filing Date

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Group Art Unit

2875

## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

## U.S. PATENT APPLICATION PUBLICATIONS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

## FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
JMH		2002-79605	03/19/2002	JAPAN				
JMH		WO 02/04858	01/17/2002	PCT				
JMH		08-327807	12/13/1996	JAPAN				

## OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

JMH		Office Action by Chinese Patent Office dated July 29, 2005.

EXAMINER

*[Signature]*

DATE CONSIDERED

*January 25, 2006*

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